

Search Report

EIC 1700

STIC Database Tracking Number: 10/554242

To: MICHAEL BERNSTEYN
Location: REM-10D25
Art Unit: 1796
Tuesday, October 16, 2007

Case Serial Number: 10/554242

From: MEI HUANG
Location: EIC1700
REM-4B28 / REM-4B31
Phone: (571)272-3952

mei.huang@uspto.gov

Search Notes

Examiner BERNSTEYN:

Please feel free to contact me if you have any questions or if you would like to refine the search query. Thank you for using STIC services!

Regards,
Mei



SCIENTIFIC REFERENCE BR
Sci & Tech Inf. Ctr.
OCT 16 2007
Pat. & T.M. Office

Please search this as soon as possible.
Leah

Access DB# 240389

RUSH SEARCH REQUEST FORM

Scientific and Technical Information Center

Requester's Full Name: Michael Bernshteyn Examiner #: 81515 Date: 10/16/07
Art Unit: 1796 Phone Number 302 772-2411 Serial Number: 10/554,242
Mail Box and Bldg/Room Location: Box 10025 Results Format Preferred (circle): PAPER DISK E-MAIL

If more than one search is submitted, please prioritize searches in order of need.

Please provide a detailed statement of the search topic, and describe as specifically as possible the subject matter to be searched. Include the elected species or structures, keywords, synonyms, acronyms, and registry numbers, and combine with the concept or utility of the invention. Define any terms that may have a special meaning. Give examples or relevant citations, authors, etc, if known. Please attach a copy of the cover sheet, pertinent claims, and abstract.

Title of Invention: Process For production of living-radical polymers
Inventors (please provide full names): Shigeru Yamago; Junichi Yoshida,
Takashi Kamoshima

Earliest Priority Filing Date: 04/25/2003

For Sequence Searches Only Please include all pertinent information (parent, child, divisional, or issued patent numbers) along with the appropriate serial number.

Please, try to find a polymer initiator according claims 1-3, comprising an organotellurium compound of formula (1), ditelluride of formula (2) and a 20 initiator.

Thank you

M. Bernshteyn

STAFF USE ONLY		Type of Search	Vendors and cost where applicable
Searcher:	<u>MH</u>	NA Sequence (#)	STN <input checked="" type="checkbox"/>
Searcher Phone #:		AA Sequence (#)	Dialog <input type="checkbox"/>
Searcher Location:		Structure (#)	Questel/Orbit <input type="checkbox"/>
Date Searcher Picked Up:	<u>10/16/07</u>	Bibliographic	Dr. Link <input type="checkbox"/>
Date Completed:	<u>10/16/07</u>	Litigation	Lexis/Nexis <input type="checkbox"/>
Searcher Prep & Review Time:		Fulltext	Sequence Systems <input type="checkbox"/>
Clerical Prep Time:		Patent Family	WWW/Internet <input type="checkbox"/>
Online Time:		Other	Other (specify) _____



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Bib Data Sheet

CONFIRMATION NO. 6569

SERIAL NUMBER 10/554,242	FILING OR 371(c) DATE 10/25/2005 RULE	CLASS 526	GROUP ART UNIT 1713	ATTORNEY DOCKET NO. 2005-1665A
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APPLICANTS

Shigeru Yamago, Ichijoji-sagaramatsu cho, JAPAN;
 Junichi Yoshida, Higashikorimotomachi, JAPAN;
 Takashi Kameshima, Kagasuno, JAPAN;

** CONTINUING DATA *****

This application is a 371 of PCT/JP04/05989 04/26/2004

** FOREIGN APPLICATIONS *****

JAPAN 2003-121223 04/25/2003

IF REQUIRED, FOREIGN FILING LICENSE GRANTED

** 05/30/2006

Foreign Priority claimed <input checked="" type="checkbox"/> yes <input type="checkbox"/> no	STATE OR COUNTRY JAPAN	SHEETS DRAWING 0	TOTAL CLAIMS 3	INDEPENDENT CLAIMS 3
35 USC 119 (a-d) conditions <input checked="" type="checkbox"/> yes <input type="checkbox"/> no <input type="checkbox"/> Met after met Verifier and Acknowledged <i>M. Bernsdeijn MB</i> Allowance Examiner's Signature Initials				

ADDRESS

513

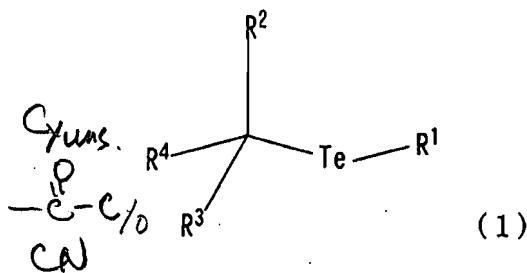
TITLE

Process for production of living-radical polymers and polymers

FILING FEE RECEIVED 900	FEES: Authority has been given in Paper No. _____ to charge/credit DEPOSIT ACCOUNT No. _____ for following:	<input type="checkbox"/> All Fees <input type="checkbox"/> 1.16 Fees (Filing) <input type="checkbox"/> 1.17 Fees (Processing Ext. of time) <input type="checkbox"/> 1.18 Fees (Issue) <input type="checkbox"/> Other <input type="checkbox"/> Credit
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Amendments to the Claims

1. (Currently amended) A process for producing a living radical polymer which comprises polymerizing a vinyl monomer in the presence of an organotellurium compound represented by the formula (1), an azo type polymerization initiator and a ditelluride compound represented by the formula (2)

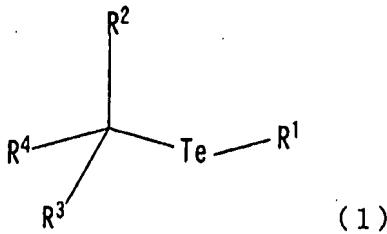


wherein R^1 is C_1-C_8 alkyl, aryl, substituted aryl or an aromatic heterocyclic group, R^2 and R^3 are each a hydrogen atom or C_1-C_8 alkyl, and R^4 is aryl, substituted aryl, an aromatic heterocyclic group, acyl, oxycarbonyl or cyano,



wherein R^1 is the same as above, to obtain a living radical polymer having a molecular weight distribution of 1.05 to 1.50.

2. (Currently amended) A living radical polymer having a molecular weight distribution of 1.05 to 1.50 produced by polymerizing a vinyl monomer in the presence of an organotellurium compound represented by the formula (1), an azo type polymerization initiator and a ditelluride compound represented by the formula (2)

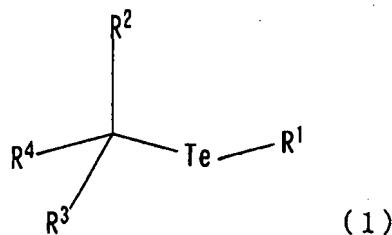


wherein R¹ is C₁-C₈ alkyl, aryl, substituted aryl or an aromatic heterocyclic group, R² and R³ are each a hydrogen atom or C₁-C₈ alkyl, and R⁴ is aryl, substituted aryl, an aromatic heterocyclic group, acyl, oxycarbonyl or cyano,



wherein R¹ is the same as above.

3. (Previously presented) A mixture of an organotellurium compound represented by the formula (1), an azo type polymerization initiator and a ditelluride compound represented by the formula (2)



wherein R¹ is C₁-C₈ alkyl, aryl, substituted aryl or an aromatic heterocyclic group, R² and R³ are each a hydrogen atom or C₁-C₈ alkyl, and R⁴ is aryl, substituted aryl, an aromatic heterocyclic group, acyl, oxycarbonyl or cyano,



wherein R¹ is the same as above.



STIC Search Results Feedback Form

EIC17000

Questions about the scope or the results of the search? Contact *the EIC searcher or contact:*

Kathleen Fuller, EIC 1700 Team Leader
571/272-2505 REMSEN 4B28

Voluntary Results Feedback Form

➤ I am an examiner in Workgroup: Example: 1713

➤ Relevant prior art found, search results used as follows:

- 102 rejection
- 103 rejection
- Cited as being of interest.
- Helped examiner better understand the invention.
- Helped examiner better understand the state of the art in their technology.

Types of relevant prior art found:

- Foreign Patent(s)
- Non-Patent Literature
(journal articles, conference proceedings, new product announcements etc.)

➤ Relevant prior art not found:

- Results verified the lack of relevant prior art (helped determine patentability).
- Results were not useful in determining patentability or understanding the invention.

Comments:

Drop off or send completed forms to EIC1700/REMSEN/4B28

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STRUCTURE FILE UPDATES: 15 OCT 2007 HIGHEST RN 950725-14-1
DICTIONARY FILE UPDATES: 15 OCT 2007 HIGHEST RN 950725-14-1

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TSCA INFORMATION NOW CURRENT THROUGH June 29, 2007

Please note that search-term pricing does apply when conducting SmartSELECT searches.

REGISTRY includes numerically searchable data for experimental and predicted properties as well as tags indicating availability of experimental property data in the original document. For information on property searching in REGISTRY, refer to:

<http://www.cas.org/support/stngen/stndoc/properties.html>

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=> d que stat l13
L4                      STR
Te~^C
1 2
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NODE ATTRIBUTES:

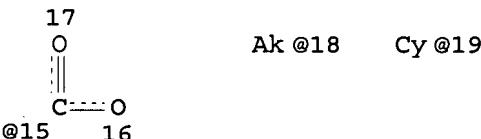
NSPEC IS RC AT 2
DEFAULT MLEVEL IS ATOM
DEFAULT ECLEVEL IS LIMITED

GRAPH ATTRIBUTES:

RING(S) ARE ISOLATED OR EMBEDDED
NUMBER OF NODES IS 2

STEREO ATTRIBUTES: NONE

L6 SCR 2040
L8 8193 SEA FILE=REGISTRY SSS FUL L4 NOT L6
L11 STR



VAR G1=5/6/8

VAR G2=11/12/15/CN

VAR G3=18/19

NODE ATTRIBUTES:

DEFAULT MLEVEL IS ATOM
 GGCAT IS SAT AT 7
 GGCAT IS SAT AT 9
 GGCAT IS SAT AT 10
 GGCAT IS UNS AT 11
 GGCAT IS SAT AT 18
 GGCAT IS UNS AT 19
 DEFAULT ECLEVEL IS LIMITED
 ECOUNT IS M1-X8 C AT 7
 ECOUNT IS M1-X8 C AT 9
 ECOUNT IS M1-X8 C AT 10
 ECOUNT IS M1-X8 C AT 18

GRAPH ATTRIBUTES:

RING(S) ARE ISOLATED OR EMBEDDED
 NUMBER OF NODES IS 19

STEREO ATTRIBUTES: NONE

L13 244 SEA FILE=REGISTRY SUB=L8 SSS FUL L11

100.0% PROCESSED 8193 ITERATIONS
 SEARCH TIME: 00.00.01

244 ANSWERS

=> d que stat 116
 L4 STR

Te~^C
 1 2

NODE ATTRIBUTES:

NSPEC IS RC AT 2
 DEFAULT MLEVEL IS ATOM
 DEFAULT ECLEVEL IS LIMITED

GRAPH ATTRIBUTES:

RING(S) ARE ISOLATED OR EMBEDDED
 NUMBER OF NODES IS 2

STEREO ATTRIBUTES: NONE

L6 SCR 2040
 L8 8193 SEA FILE=REGISTRY SSS FUL L4 NOT L6
 L10 STR

G1~^Te~^ Te~^ G1 Ak @5 Cy @6
 4 3 1 2

VAR G1=5/6

NODE ATTRIBUTES:

DEFAULT MLEVEL IS ATOM
 GGCAT IS SAT AT 5
 GGCAT IS UNS AT 6
 DEFAULT ECLEVEL IS LIMITED
 ECOUNT IS M1-X8 C AT 5

GRAPH ATTRIBUTES:

RING(S) ARE ISOLATED OR EMBEDDED
NUMBER OF NODES IS 6

STEREO ATTRIBUTES: NONE

L16 445 SEA FILE=REGISTRY SUB=L8 SSS FUL L10

100.0% PROCESSED 736 ITERATIONS
SEARCH TIME: 00.00.01

445 ANSWERS

=> d his

(FILE 'HOME' ENTERED AT 14:48:18 ON 16 OCT 2007)

FILE 'HCAPLUS' ENTERED AT 14:48:27 ON 16 OCT 2007
E US20060199927/PN

L1 1 S E3
SEL RN

FILE 'REGISTRY' ENTERED AT 14:48:53 ON 16 OCT 2007
L2 33 S E1-33
L3 6 S L2 AND TE/ELS

FILE 'LREGISTRY' ENTERED AT 15:02:03 ON 16 OCT 2007
L4 STR

FILE 'REGISTRY' ENTERED AT 15:03:33 ON 16 OCT 2007
L5 50 S L4
L6 SCR 2040
L7 50 S L4 NOT L6
L8 8193 S L4 NOT L6 FUL
L9 5 S L2 AND L8
SAV L8 BER242/A

FILE 'LREGISTRY' ENTERED AT 15:04:45 ON 16 OCT 2007
L10 STR L4
L11 STR L4

FILE 'REGISTRY' ENTERED AT 15:20:30 ON 16 OCT 2007
L12 15 S L11 SSS SAM SUB=L8
L13 244 S L11 SSS FUL SUB=L8
L14 3 S L2 AND L13
SAV L13 BER242S1/A
L15 24 S L10 SSS SAM SUB=L8
L16 445 S L10 SSS FUL SUB=L8
L17 2 S L2 AND L16
SAV L16 BER242S2/A

FILE 'HCAPLUS' ENTERED AT 15:23:45 ON 16 OCT 2007
L18 183 S L13
L19 1141 S L16
L20 58 S L18 AND L19
L21 16 S L13(L)CAT/RL
L22 27 S L16(L)CAT/RL
L23 5 S L21 AND L22
L24 QUE CATALYST
L25 14 S L20 AND L24
L26 QUE INITIAT? OR INIT#
L27 7 S L20 AND L26
L28 15 S L25 OR L27

L29 10 S L28 NOT L23

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FILE COVERS 1907 - 16 Oct 2007 VOL 147 ISS 17
FILE LAST UPDATED: 15 Oct 2007 (20071015/ED)

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=> d 123 ibib abs hitstr hitind 1-5

L23 ANSWER 1 OF 5 HCAPLUS COPYRIGHT 2007 ACS on STN
ACCESSION NUMBER: 2006:888365 HCAPLUS
DOCUMENT NUMBER: 145:272431
TITLE: Manufacture of aqueous polymer solutions using organotellurium compounds
INVENTOR(S): Okubo, Masayoshi; Kameshima, Takashi; Kono, Kazuhiro; Makoto, Takeshi
PATENT ASSIGNEE(S): Kobe University, Japan; Otsuka Chemical Co., Ltd.
SOURCE: Jpn. Kokai Tokkyo Koho, 17pp.
CODEN: JKXXAF
DOCUMENT TYPE: Patent
LANGUAGE: Japanese
FAMILY ACC. NUM. COUNT: 1
PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
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JP 2006225524	A	20060831	JP 2005-41321	200502 17
PRIORITY APPLN. INFO.:			JP 2005-41321	200502 17

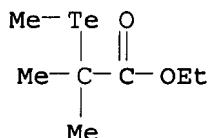
OTHER SOURCE(S): MARPAT 145:272431
AB Vinyl monomers are polymerized in aqueous media by using R1TeCR2R3R4 [R1 = C1-8 alkyl, (un)substituted aryl, aromatic heterocyclic group; R2, R3 =

H, C1-8 alkyl; R4 = (un)substituted aryl, aromatic heterocyclic group, acyl, oxycarbonyl, cyano] and surfactants and/or dispersing agents to give the aqueous solns. The aqueous solns. are used as macroinitiators in polymerization of vinyl monomers. Thus, Me methacrylate was polymerized at 60° for 24 h in H₂O in the presence of ethyl-2-methyl-2-butyltellanyl propionate, di-Bu ditelluride, AIBN, and Na dodecylsulfonate to give an aqueous PMMA emulsion with conversion 77%, Mn 20,900 and Mw/Mn 1.36.

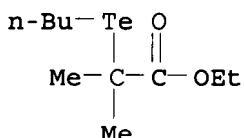
IT 20334-43-4P, Dimethyl ditelluride 474094-06-9P
 658058-35-6P
 RL: CAT (Catalyst use); IMF (Industrial manufacture); PREP (Preparation); USES (Uses)
 (manufacture of aqueous polymer solns. using organotellurium compds.)
 RN 20334-43-4 HCPLUS
 CN Ditelluride, dimethyl (9CI) (CA INDEX NAME)



RN 474094-06-9 HCPLUS
 CN Propanoic acid, 2-methyl-2-(methyltelluro)-, ethyl ester (CA INDEX NAME)



RN 658058-35-6 HCPLUS
 CN Propanoic acid, 2-(butyltelluro)-2-methyl-, ethyl ester (CA INDEX NAME)



CC 37-3 (Plastics Manufacture and Processing)
 IT 20334-43-4P, Dimethyl ditelluride 474094-06-9P
 658058-35-6P
 RL: CAT (Catalyst use); IMF (Industrial manufacture); PREP (Preparation); USES (Uses)
 (manufacture of aqueous polymer solns. using organotellurium compds.)

L23 ANSWER 2 OF 5 HCPLUS COPYRIGHT 2007 ACS on STN

ACCESSION NUMBER: 2005:428591 HCPLUS

DOCUMENT NUMBER: 142:454333

TITLE: Radiation-sensitive chemically amplified positive-working resists

INVENTOR(S): Nishimura, Isao; Kobayashi, Eiichi; Seyano, Akimasa; Wang, Yong

PATENT ASSIGNEE(S): JSR Ltd., Japan

SOURCE: Jpn. Kokai Tokkyo Koho, 44 pp.

CODEN: JKXXAF
 DOCUMENT TYPE: Patent
 LANGUAGE: Japanese
 FAMILY ACC. NUM. COUNT: 1
 PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
JP 2005128049	A	20050519	JP 2003-360291	200310 21
PRIORITY APPLN. INFO.:			JP 2003-360291	200310 21

OTHER SOURCE(S): MARPAT 142:454333

AB The resists comprise alkali-insol. polymers having acid-labile groups increasing solubility in alkaline solns. upon contact with acids, and radiation-sensitive acid generators, wherein the polymers are prepared by using RbC(Rc)(Rd)TeRa [Ra = C1-8 alkyl, (substituted) aryl, atom. heterocycle; Rb, Rc = H, C1-8 alkyl; Rd = (substituted) aryl, aromatic heterocycle, acyl, etc.], and optionally ditellurides (RaTe)₂ as radical living polymerization initiators. In the polymerization, radical polymerization

initiators may also be employed. The polymers has narrow mol.-weight distribution peaks with small lot-to-lot fluctuation and resultant resists show high transparency and sensitivity for far UV, x rays, and electron rays, and high dry etching resistance, and provide fine patterns with good profile.

IT 20334-43-4P, Dimethyl ditelluride 77129-69-2P,
 Di(butyl) ditelluride 474094-06-9P 658058-35-6P
 RL: CAT (Catalyst use); IMF (Industrial manufacture); PREP (Preparation); USES (Uses)
 (radical living polymerization initiator, for preparing polymer; radiation-sensitive pos.-working resist containing polymer prepared by using radical living polymerization)

RN 20334-43-4 HCPLUS

CN Ditelluride, dimethyl (9CI) (CA INDEX NAME)

H₃C—Te—Te—CH₃

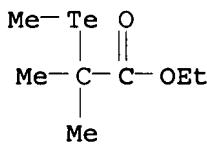
RN 77129-69-2 HCPLUS

CN Ditelluride, dibutyl (CA INDEX NAME)

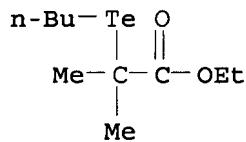
n-Bu—Te—Te—Bu-n

RN 474094-06-9 HCPLUS

CN Propanoic acid, 2-methyl-2-(methyltelluro)-, ethyl ester (CA INDEX NAME)



RN 658058-35-6 HCAPLUS
 CN Propanoic acid, 2-(butyltelluro)-2-methyl-, ethyl ester (CA INDEX
 NAME)



IC ICM G03F007-039
 ICS C08F004-72; H01L021-027; C08F020-00
 CC 74-5 (Radiation Chemistry, Photochemistry, and Photographic and
 Other Reprographic Processes)
 Section cross-reference(s): 35, 38
 IT 20334-43-4P, Dimethyl ditelluride 77129-69-2P,
 Di(butyl) ditelluride 474094-06-9P 658058-35-6P
 RL: CAT (Catalyst use); IMF (Industrial manufacture); PREP
 (Preparation); USES (Uses)
 (radical living polymerization initiator, for preparing polymer;
 radiation-sensitive pos.-working resist containing polymer prepared by
 using radical living polymerization)

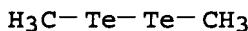
L23 ANSWER 3 OF 5 HCAPLUS COPYRIGHT 2007 ACS on STN
 ACCESSION NUMBER: 2005:428239 HCAPLUS
 DOCUMENT NUMBER: 142:464450
 TITLE: Acid-dissociating group-containing acrylic
 polymers with narrow molecular weight
 distribution and their manufacture
 INVENTOR(S): Nishimura, Isao; Wang, Yong; Kameshima, Takashi
 PATENT ASSIGNEE(S): JSR Ltd., Japan; Otsuka Chemical Co., Ltd.
 SOURCE: Jpn. Kokai Tokkyo Koho, 37 pp.
 CODEN: JKXXAF
 DOCUMENT TYPE: Patent
 LANGUAGE: Japanese
 FAMILY ACC. NUM. COUNT: 1
 PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
JP 2005126459	A	20050519	JP 2003-360290	200310 21
PRIORITY APPLN. INFO.:			JP 2003-360290	200310 21

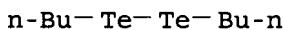
OTHER SOURCE(S): MARPAT 142:464450
 AB The polymers, especially useful for lithog., are manufactured in the presence

(1) R1TeCR2R3R4 [I; R1 = C1-8 alkyl, (un)substituted aryl, aromatic heterocyclic; R2,3 = H, C1-8 alkyl; R4 = (un)substituted aryl, aromatic heterocyclic, acyl, oxycarbonyl, cyano] or (2) mixts. of ≥ 1 compds. selected from I, radical polymerization initiators, and (R5Te)2 (R5 = same as R1). Thus, 3.5 mmol 2-méthyl-2-propenoic acid hexahydro-2-oxo-3,5-methano-2H-cyclopenta[b]furan-6-yl ester, 1.5 mmol 2-methyl-2-propenoic acid 3-hydroxytricyclo[3.3.1.13,7]dec-1-yl ester, and 5 mmol 2-methyl-2-propenoic acid 2-methyltricyclo[3.3.1.13,7]dec-2-yl ester were polymerized in the presence of Et 2-methyl-2-(butyltelluro)propanoate (0.2 mmol), dibutyltelluride (0.10 mmol), and MAIB (0.10 mmol) to give a copolymer (yield 85%) showing M_w 10000, M_w/M_n 1.24, good solubility to propylene glycol monomethyl ether acetate, and decreased M_w fluctuation.

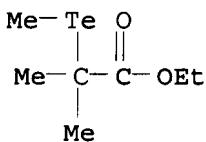
IT 20334-43-4P, Dimethylditelluride 77129-69-2P,
Dibutylditelluride 474094-06-9P 658058-35-6P
RL: CAT (Catalyst use); IMF (Industrial manufacture); PREP
(Preparation); USES (Uses)
(living polymerization initiator; acid-dissociating group-containing acrylic
polymers with narrow mol. weight distribution)
RN 20334-43-4 HCPLUS
CN Ditelluride, dimethyl (9CI) (CA INDEX NAME)



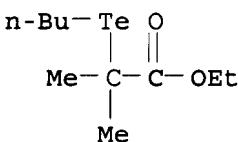
RN 77129-69-2 HCAPLUS
CN Ditelluride, dibutyl (CA INDEX NAME)



RN 474094-06-9 HCAPLUS
CN Propanoic acid, 2-methyl-2-(methyltelluro)-, ethyl ester (CA INDEX NAME)



RN 658058-35-6 HCAPLUS
CN Propanoic acid, 2-(butyltelluro)-2-methyl-, ethyl ester (CA INDEX NAME)



IC ICM C08F004-00
ICS C08F020-10; G03F007-033; G03F007-039; C07C395-00

CC 37-3 (Plastics Manufacture and Processing)
 Section cross-reference(s): 74
 IT 20334-43-4P, Dimethylditelluride 77129-69-2P,
 Dibutylditelluride 474094-06-9P 658058-35-6P
 RL: CAT (Catalyst use); IMF (Industrial manufacture); PREP
 (Preparation); USES (Uses)
 (living polymerization initiator; acid-dissociating group-containing acrylic
 polymers with narrow mol. weight distribution)

L23 ANSWER 4 OF 5 HCAPLUS COPYRIGHT 2007 ACS on STN

ACCESSION NUMBER: 2004:965297 HCAPLUS
 DOCUMENT NUMBER: 141:411400
 TITLE: Process for production of living-radical
 polymers and polymers
 INVENTOR(S): Yamago, Shigeru; Yoshida, Junichi; Kameshima,
 Takashi
 PATENT ASSIGNEE(S): Otsuka Chemical Co., Ltd., Japan
 SOURCE: PCT Int. Appl., 51 pp.
 CODEN: PIXXD2
 DOCUMENT TYPE: Patent
 LANGUAGE: Japanese
 FAMILY ACC. NUM. COUNT: 1
 PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE		
WO 2004096870	A1	20041111	WO 2004-JP5989	200404 26		
W: AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BW, BY, BZ, CA, CH, CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, EG, ES, FI, GB, GD, GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NA, NI, NO, NZ, OM, PG, PH, PL, PT, RO, RU, SC, SD, SE, SG, SK, SL, SY, TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, YU, ZA, ZM, ZW	RW: BW, GH, GM, KE, LS, MW, MZ, NA, SD, SL, SZ, TZ, UG, ZM, ZW, AM, AZ, BY, KG, KZ, MD, RU, TJ, TM, AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HU, IE, IT, LU, MC, NL, PL, PT, RO, SE, SI, SK, TR, BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG	EP 1619211	A1	20060125	EP 2004-729496	200404 26
CN 1780860	A	20060531	CN 2004-80011197	200404 26		
JP 3845109	B2	20061115	JP 2005-505899	200404 26		
US 2006199927	A1	20060907	US 2005-554242	200510 25		
PRIORITY APPLN. INFO.:			JP 2003-121223	A	200304 25	

WO 2004-JP5989

W

200404
26

OTHER SOURCE(S) : MARPAT 141:411400

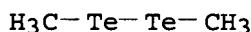
AB The polymers are prepared by polymerizing vinyl monomers by using an azo initiator, an organotellurium compound R₁TeCR₂R₃R₄ and a ditelluride compound (R₁Te)₂ [R₁ = C₁₋₈ alkyl, (un)substituted aryl, aromatic heterocyclic group; R₂, R₃ = H, C₁₋₈ alkyl; R₄ = (un)substituted aryl, aromatic heterocyclic group, acyl, oxycarbonyl, cyanol]. Thus, 10 mmol Me methacrylate was polymerized in the presence of AIBN 0.10, dimethylditelluride 0.10, and 2-methyl-2-methyltellurylpropionitrile 0.10 mmol at 60° for 2 h to give 98% PMMA with Mn 9600 and Mw/Mn 1.15.

IT 20334-43-4P, Dimethylditelluride 77129-69-2P,
Dibutylditelluride 474094-06-9P 582319-76-4P
658058-35-6P

RL: CAT (Catalyst use); IMF (Industrial manufacture); PREP (Preparation); USES (Uses)
(organotellurium catalysts for preparation of living-radical polymers)

RN 20334-43-4 HCPLUS

CN Ditelluride, dimethyl (9CI) (CA INDEX NAME)



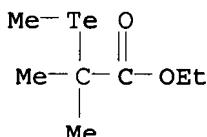
RN 77129-69-2 HCPLUS

CN Ditelluride, dibutyl (CA INDEX NAME)



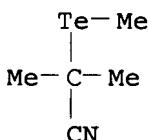
RN 474094-06-9 HCPLUS

CN Propanoic acid, 2-methyl-2-(methyltelluro)-, ethyl ester (CA INDEX NAME)



RN 582319-76-4 HCPLUS

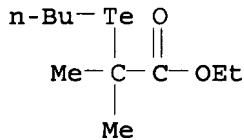
CN Propanenitrile, 2-methyl-2-(methyltelluro)- (CA INDEX NAME)



RN 658058-35-6 HCPLUS

CN Propanoic acid, 2-(butyltelluro)-2-methyl-, ethyl ester (CA INDEX

NAME)



IC ICM C08F004-00
CC 35-3 (Chemistry of Synthetic High Polymers)
Section cross-reference(s): 29, 67
IT 20334-43-4P, Dimethylditelluride 77129-69-2P,
Dibutylditelluride 474094-06-9P 582319-76-4P
658058-35-6P
RL: CAT (Catalyst use); IMF (Industrial manufacture); PREP
(Preparation); USES (Uses)
(organotellurium catalysts for preparation of living-radical polymers)
REFERENCE COUNT: 3 THERE ARE 3 CITED REFERENCES AVAILABLE FOR
THIS RECORD. ALL CITATIONS AVAILABLE IN
THE RE FORMAT

L23 ANSWER 5 OF 5 HCPLUS COPYRIGHT 2007 ACS on STN
ACCESSION NUMBER: 2004:143194 HCPLUS
DOCUMENT NUMBER: 140:181982
TITLE: Process for production of living radical
polymers and block polymers
INVENTOR(S): Yamago, Shigeru; Yoshida, Junichi
PATENT ASSIGNEE(S): Otsuka Chemical Co., Ltd., Japan
SOURCE: PCT Int. Appl., 51 pp.
CODEN: PIXXD2
DOCUMENT TYPE: Patent
LANGUAGE: Japanese
FAMILY ACC. NUM. COUNT: 1
PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
WO 2004014962	A1	20040219	WO 2003-JP10116	20030808
W: AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BY, BZ, CA, CH, CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, ES, FI, GB, GD, GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NI, NO, NZ, OM, PH, PL, PT, RO, RU, SC, SD, SE, SG, SK, SL, TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, YU, ZA, ZM, ZW				
RW: GH, GM, KE, LS, MW, MZ, SD, SL, SZ, TZ, UG, ZM, ZW, AM, AZ, BY, KG, KZ, MD, RU, TJ, TM, AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HU, IE, IT, LU, MC, NL, PT, RO, SE, SI, SK, TR, BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG				
CA 2494983	A1	20040219	CA 2003-2494983	20030808
AU 2003254890	A1	20040225	AU 2003-254890	20030808

AU 2003254890	B2	20070823	08
EP 1541592	A1	20050615	EP 2003-784600
			200308
			08
EP 1541592	B1	20070502	
R: AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC, PT, IE, SI, LT, LV, FI, RO, MK, CY, AL, TR, BG, CZ, EE, HU, SK			
CN 1675253	A	20050928	CN 2003-819158
			200308
			08
RU 2285010	C2	20061010	RU 2005-106221
			200308
			08
JP 3839829	B2	20061101	JP 2004-527371
			200308
			08
AT 361322	T	20070515	AT 2003-784600
			200308
			08
CN 101029117	A	20070905	CN 2007-10084346
			200308
			08
US 2006167199	A1	20060727	US 2005-523611
			200502
			07
JP 2006299278	A	20061102	JP 2006-172603
			200606
			22
IN 2007DN06928	A	20070928	IN 2007-DN6928
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			07
PRIORITY APPLN. INFO.:		JP 2002-231917	A
			200208
			08
		CN 2003-819158	A3
			200308
			08
		JP 2004-527371	A3
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			08
		WO 2003-JP10116	W
			200308
			08
		IN 2005-DN556	A3
			200502
			14

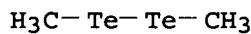
OTHER SOURCE(S): MARPAT 140:181982

AB Vinyl monomers (e.g., MMA, styrene) are polymerized by using living radical polymerization initiators R₁TeCR₂R₃R₄ and (R₁Te)₂ [R₁ = C₁₋₈ alkyl, (un)substituted aryl, aromatic heterocyclic group; R₂, R₃ = H, C₁₋₈ alkyl; R₄ = (un)substituted aryl, aromatic heterocyclic group, acyl, oxycarbonyl, cyano]. The initiators enable precise control of mol. weight and mol.-weight distribution under mild conditions. Thus, poly(Me

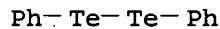
methacrylate) (Mn 9000, Mw/Mn 1.18) was prepared by using (1-methyltelluranyl ethyl)benzene and di-Me ditelluride as initiators.

IT 20334-43-4P, Dimethyl ditelluride 32294-60-3P,
 Diphenyl ditelluride 77129-69-2P, Dibutyl ditelluride
 415679-75-3P 474094-06-9P 658058-30-1P
 658058-31-2P 658058-32-3P 658058-33-4P
 658058-34-5P 658058-35-6P
 RL: CAT (Catalyst use); IMF (Industrial manufacture); PREP
 (Preparation); USES (Uses)
 (organotellurium compds. as living radical polymerization catalysts for
 preparation of polymers and block polymers)

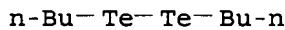
RN 20334-43-4 HCAPLUS
 CN Ditelluride, dimethyl (9CI) (CA INDEX NAME)



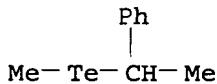
RN 32294-60-3 HCAPLUS
 CN Ditelluride, diphenyl (CA INDEX NAME)



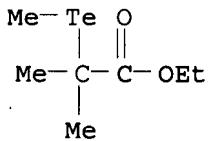
RN 77129-69-2 HCAPLUS
 CN Ditelluride, dibutyl (CA INDEX NAME)



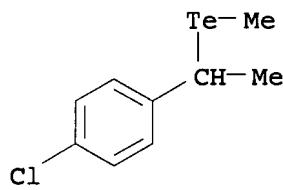
RN 415679-75-3 HCAPLUS
 CN Benzene, [1-(methyltelluro)ethyl]- (CA INDEX NAME)



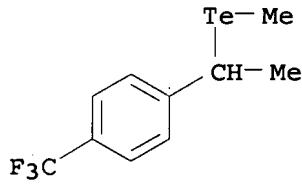
RN 474094-06-9 HCAPLUS
 CN Propanoic acid, 2-methyl-2-(methyltelluro)-, ethyl ester (CA INDEX NAME)



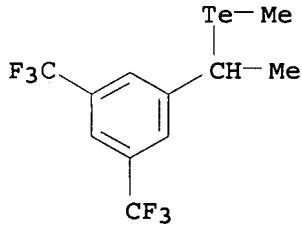
RN 658058-30-1 HCAPLUS
 CN Benzene, 1-chloro-4-[1-(methyltelluro)ethyl]- (CA INDEX NAME)



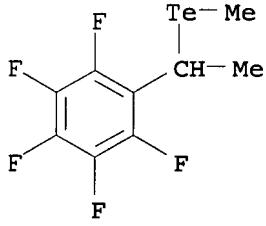
RN 658058-31-2 HCPLUS
 CN Benzene, 1-[1-(methyltelluro)ethyl]-4-(trifluoromethyl)- (CA INDEX NAME)



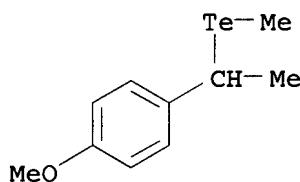
RN 658058-32-3 HCPLUS
 CN Benzene, 1-[1-(methyltelluro)ethyl]-3,5-bis(trifluoromethyl)- (CA INDEX NAME)



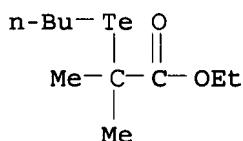
RN 658058-33-4 HCPLUS
 CN Benzene, pentafluoro[1-(methyltelluro)ethyl]- (9CI) (CA INDEX NAME)



RN 658058-34-5 HCPLUS
 CN Benzene, 1-methoxy-4-[1-(methyltelluro)ethyl]- (CA INDEX NAME)



RN 658058-35-6 HCPLUS
 CN Propanoic acid, 2-(butyltelluro)-2-methyl-, ethyl ester (CA INDEX
 NAME)



IC ICM C08F004-00
 ICS C08F297-00
 CC 35-3 (Chemistry of Synthetic High Polymers)
 Section cross-reference(s): 29, 67
 IT 20334-43-4P, Dimethyl ditelluride 32294-60-3P,
 Diphenyl ditelluride 77129-69-2P, Dibutyl ditelluride
 415679-75-3P 474094-06-9P 658058-30-1P
 658058-31-2P 658058-32-3P 658058-33-4P
 658058-34-5P 658058-35-6P
 RL: CAT (Catalyst use); IMF (Industrial manufacture); PREP
 (Preparation); USES (Uses)
 (organotellurium compds. as living radical polymerization catalysts for
 preparation of polymers and block polymers)

REFERENCE COUNT: 2 THERE ARE 2 CITED REFERENCES AVAILABLE FOR
 THIS RECORD. ALL CITATIONS AVAILABLE IN
 THE RE FORMAT

=> d 129 ibib abs hitstr hitind 1-10

L29 ANSWER 1 OF 10 HCPLUS COPYRIGHT 2007 ACS on STN
 ACCESSION NUMBER: 2007:177865 HCPLUS
 DOCUMENT NUMBER: 146:422351
 TITLE: Kinetic Study on Role of Ditelluride in
 Organotellurium-Mediated Living Radical
 Polymerization (TERP)
 AUTHOR(S): Kwak, Yungwan; Tezuka, Miho; Goto, Atsushi;
 Fukuda, Takeshi; Yamago, Shigeru
 CORPORATE SOURCE: Institute for Chemical Research, Kyoto
 University, Uji, Kyoto, 611-0011, Japan
 SOURCE: Macromolecules (Washington, DC, United States)
 (2007), 40(6), 1881-1885
 CODEN: MAMOBX; ISSN: 0024-9297
 PUBLISHER: American Chemical Society
 DOCUMENT TYPE: Journal
 LANGUAGE: English
 AB The role of di-Me ditelluride (MeTe)2 for the organotellurium-
 mediated living radical polymers. (TERPs) of styrene (St) and Me
 methacrylate (MMA) was kinetically studied. For both St and MMA,

there was a rapid reversible activation-deactivation process mediated by (MeTe)₂, i.e., P-TeMe + MeTe[•] . dblarw. P[•] + (MeTe)₂: (MeTe)₂ worked as an efficient deactivator of the propagating radical P[•], and the radical MeTe[•] worked as a highly reactive activator of the dormant species P-TeMe. This rapid reversible process accounted for the dramatic improvement of the polydispersity controllability with the addition of even a small amount of (MeTe)₂ for these polymers.

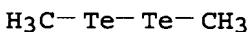
IT 20334-43-4, Dimethyl ditelluride

RL: CAT (Catalyst use); PEP (Physical, engineering or chemical process); PROC (Process); USES (Uses)

(kinetic study on role of ditelluride in organotellurium-mediated living radical polymerization)

RN 20334-43-4 HCAPLUS

CN Ditelluride, dimethyl (9CI) (CA INDEX NAME)



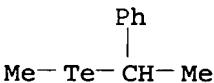
IT 415679-75-3

RL: PRP (Properties)

(model compound; kinetic study on role of ditelluride in organotellurium-mediated living radical polymerization)

RN 415679-75-3 HCAPLUS

CN Benzene, [1-(methyltelluro)ethyl]- (CA INDEX NAME)



CC 35-3 (Chemistry of Synthetic High Polymers)

IT Polymerization catalysts

Polymerization kinetics

(living, radical; kinetic study on role of ditelluride in organotellurium-mediated living radical polymerization)

IT 20334-43-4, Dimethyl ditelluride

RL: CAT (Catalyst use); PEP (Physical, engineering or chemical process); PROC (Process); USES (Uses)

(kinetic study on role of ditelluride in organotellurium-mediated living radical polymerization)

IT 415679-75-3

RL: PRP (Properties)

(model compound; kinetic study on role of ditelluride in organotellurium-mediated living radical polymerization)

REFERENCE COUNT: 41 THERE ARE 41 CITED REFERENCES AVAILABLE FOR THIS RECORD. ALL CITATIONS AVAILABLE IN THE RE FORMAT

L29 ANSWER 2 OF 10 HCAPLUS COPYRIGHT 2007 ACS on STN

ACCESSION NUMBER: 2004:986149 HCAPLUS

DOCUMENT NUMBER: 141:411404

TITLE: Manufacture of organotellurium compounds as living radical polymerization initiators

INVENTOR(S): Yamako, Shigeru; Yoshida, Junichi; Kameshima, Takashi

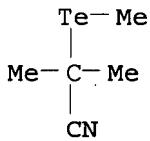
PATENT ASSIGNEE(S): Otsuka Chemical Co., Ltd., Japan

SOURCE: Jpn. Kokai Tokkyo Koho, 10 pp.

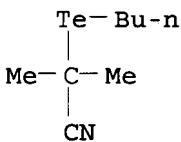
CODEN: JKXXAF
 DOCUMENT TYPE: Patent
 LANGUAGE: Japanese
 FAMILY ACC. NUM. COUNT: 1
 PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
JP 2004323437	A	20041118	JP 2003-121825	200304 25
PRIORITY APPLN. INFO.:			JP 2003-121825	200304 25

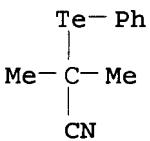
OTHER SOURCE(S): MARPAT 141:411404
 AB The compds. are manufactured by treatment of azo polymerization initiators with R1TeTeR2 (R1, R2 = C1-8 alkyl, aryl, heterocyclic group). Thus, AIBN was treated with MeTeTeMe to 17% give 2-methyl-2-methyltellanylpropionitrile.
 IT 582319-76-4P 791104-08-0P 791104-09-1P
 RL: CAT (Catalyst use); IMF (Industrial manufacture); PREP (Preparation); USES (Uses)
 (manufacture of organotellurium compds. as living radical polymerization initiators by treatment of azo polymerization initiators with ditellurides)
 RN 582319-76-4 HCPLUS
 CN Propanenitrile, 2-methyl-2-(methyltelluro)- (CA INDEX NAME)



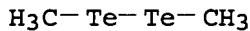
RN 791104-08-0 HCPLUS
 CN Propanenitrile, 2-(butyltelluro)-2-methyl- (CA INDEX NAME)



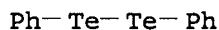
RN 791104-09-1 HCPLUS
 CN Propanenitrile, 2-methyl-2-(phenyltelluro)- (CA INDEX NAME)



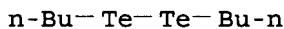
IT 20334-43-4P, Dimethyl ditelluride 32294-60-3P,
 Diphenyl ditelluride 77129-69-2P, Dibutyl ditelluride
 RL: IMF (Industrial manufacture); RCT (Reactant); PREP
 (Preparation); RACT (Reactant or reagent)
 (manufacture of organotellurium compds. as living radical polymerization
 initiators by treatment of azo polymerization initiators
 with ditellurides)
 RN 20334-43-4 HCAPLUS
 CN Ditelluride, dimethyl (9CI) (CA INDEX NAME)



RN 32294-60-3 HCAPLUS
 CN Ditelluride, diphenyl (CA INDEX NAME)



RN 77129-69-2 HCAPLUS
 CN Ditelluride, dibutyl (CA INDEX NAME)



IC ICM C07C395-00
 ICS C08F004-00
 CC 35-3 (Chemistry of Synthetic High Polymers)
 Section cross-reference(s): 23, 25
 ST organotellurium living radical polymn initiator manuf; azo
 polymn initiator ditelluride substitution; AIBN
 dimethylditelluride substitution; methyl methyltellanyl
 propionitrile polymn initiator manuf
 IT Tellurides
 RL: RCT (Reactant); RACT (Reactant or reagent)
 (ditellurides, dialkyl; manufacture of organotellurium compds. as
 living radical polymerization initiators by treatment of azo
 polymerization initiators with ditellurides)
 IT Polymerization catalysts
 (living, radical; manufacture of organotellurium compds. as living
 radical polymerization initiators by treatment of azo polymerization
 initiators with ditellurides)
 IT 109-72-8, Butyllithium, reactions 591-51-5, Phenyllithium
 917-54-4
 RL: RCT (Reactant); RACT (Reactant or reagent)
 (ditelluride manufactured from; manufacture of organotellurium compds. as
 living radical polymerization initiators by treatment of azo
 polymerization initiators with ditellurides)
 IT 582319-76-4P 791104-08-0P 791104-09-1P
 RL: CAT (Catalyst use); IMF (Industrial manufacture); PREP
 (Preparation); USES (Uses)
 (manufacture of organotellurium compds. as living radical polymerization
 initiators by treatment of azo polymerization initiators
 with ditellurides)
 IT 20334-43-4P, Dimethyl ditelluride 32294-60-3P,
 Diphenyl ditelluride 77129-69-2P, Dibutyl ditelluride
 RL: IMF (Industrial manufacture); RCT (Reactant); PREP

(Preparation); RACT (Reactant or reagent)
 (manufacture of organotellurium compds. as living radical polymerization initiators by treatment of azo polymerization initiators with ditellurides)

IT 78-67-1, AIBN

RL: RCT (Reactant); RACT (Reactant or reagent)
 (manufacture of organotellurium compds. as living radical polymerization initiators by treatment of azo polymerization initiators with ditellurides)

L29 ANSWER 3 OF 10 HCPLUS COPYRIGHT 2007 ACS on STN

ACCESSION NUMBER: 1994:164377 HCPLUS

DOCUMENT NUMBER: 120:164377

TITLE: Synthesis of α -phenylchalcogeno acetic acids, ethyl- α -phenylchalcogeno acetates and ethyl- α -halo- α -phenylchalcogeno acetates

AUTHOR(S): Dabdoub, Miguel J.; Guerrero, Palimecio G. Jr.; Silveira, Claudio C.

CORPORATE SOURCE: Departamento de Quimica - F.F.C.L., Universidade de Sao Paulo, Av. Bandeirantes, 3900, Ribeirao Preto -SP, Brazil

SOURCE: Journal of Organometallic Chemistry (1993), 460(1), 31-7

CODEN: JORCAI; ISSN: 0022-328X

DOCUMENT TYPE: Journal

LANGUAGE: English

OTHER SOURCE(S): CASREACT 120:164377

AB Reaction of PhTe- or PhSe- anion with BrCH₂CO₂H under phase-transfer conditions in liquid-solid system affords the α -(phenyltelluro)- and α -(phenylseleno)acetic acid in 44 and 50% yields, resp. Under similar reaction conditions, Ph chalcogenate anions react with BrCH₂CO₂Et give 52% PhTeCH₂CO₂Et and 47% PhSeCH₂CO₂Et, resp. Reaction of PhSeCl with N₂CHCO₂Et (I) in THF at 0° yields exclusively PhSeCHClCO₂Et in 88% yield. Similar reactions by addition of PhSeBr in THF or C₆H₆ to I at different temps. result in mixts. of PhSeCHBrCO₂Et (II) and (PhSe)₂CHCO₂Et in different ratios. However, when the I was slowly added to a solution of PhSeBr in C₆H₆ under reflux, II was obtained in 84% yield as the only product. Reaction of I with PhTeBr in C₆H₆ at room temperature results in formation of PhTeCHBrCO₂Et acetate that decomp. rapidly into the corresponding tellurone. Addition of I to a mixture of Ph₂Se₂ and CuSO₄ in refluxing C₆H₆ results in a 10:1 PhSeCH₂CO₂Et-(PhSe)₂CHCO₂Et mixture. By an alternative route, the former was obtained in 74% yield by esterification of PhSeCH₂CO₂H in C₆H₆ with EtOH-H₂SO₄, and then transformed into the α -bromo ester in 41% yield by treatment with NBS. On the other hand, the Cu-catalyzed thermal reaction of I with Ph₂Te₂ in C₆H₆ afforded PhTeCH₂CO₂Et as the only product.

IT 32294-60-3, Diphenyl ditelluride

RL: RCT (Reactant); RACT (Reactant or reagent)
 (condensation reaction of, with bromoacetic acid, phase transfer-catalyzed)

RN 32294-60-3 HCPLUS

CN Ditelluride, diphenyl (CA INDEX NAME)

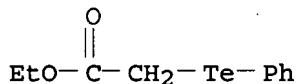
Ph—Te—Te—Ph

IT 116246-83-4P 127291-78-5P

RL: SPN (Synthetic preparation); PREP (Preparation)
(preparation of)

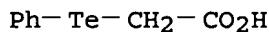
RN 116246-83-4 HCPLUS

CN Acetic acid, (phenyltelluro)-, ethyl ester (9CI) (CA INDEX NAME)



RN 127291-78-5 HCPLUS

CN Acetic acid, (phenyltelluro)- (9CI) (CA INDEX NAME)



CC 29-8 (Organometallic and Organometalloidal Compounds)

IT 112-02-7, Cetyltrimethylammonium chloride

RL: CAT (Catalyst use); USES (Uses)
(catalyst, for phase transfer-catalyzed reaction of
phenylchalcogenate anion with bromoacetate)

IT 1666-13-3, Diphenyl diselenide 32294-60-3, Diphenyl
ditelluride

RL: RCT (Reactant); RACT (Reactant or reagent)
(condensation reaction of, with bromoacetic acid, phase
transfer-catalyzed)

IT 72041-41-9P 116246-83-4P 127291-78-5P
138100-77-3P 142753-40-0P 153490-06-3P
RL: SPN (Synthetic preparation); PREP (Preparation)
(preparation of)

L29 ANSWER 4 OF 10 HCPLUS COPYRIGHT 2007 ACS on STN

ACCESSION NUMBER: 1992:59144 HCPLUS

DOCUMENT NUMBER: 116:59144

TITLE: Novel preparation of highly electrophilic
species for benzenetellurenylation or
benzenesulfenylation by nitrobenzenesulfonyl
peroxide in combination with ditelluride or
disulfide. Application to intramolecular ring
closures

AUTHOR(S): Yoshida, Masato; Suzuki, Takashi; Kamigata,
Nobumasa

CORPORATE SOURCE: Fac. Sci., Tokyo Metrop. Univ., Hachioji,
192-03, Japan

SOURCE: Journal of Organic Chemistry (1992), 57(1),
383-6
CODEN: JOCEAH; ISSN: 0022-3263

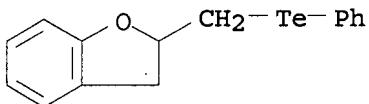
DOCUMENT TYPE: Journal

LANGUAGE: English

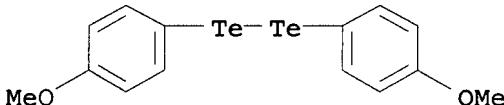
OTHER SOURCE(S): CASREACT 116:59144

AB Electrophilic intramol. ring closures of unsatd. hydroxy or carboxy
compds. were effected by nitrobenzenesulfonyl peroxide (I) in
combination with PhTe₂Ph (II) or PhS₂Ph (III). Upon treatment with
I, II was converted into an electrophilic species, which acted as an
initiator for the cyclization of unsatd. alcs. to afford
cyclic ethers. On the other hand, the electrophilic benzene
sulfenyl species, similarly prepared from I and III could be used for
phenylsulfolactonizations of unsatd. carboxylic acids.

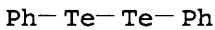
IT 122823-57-8P
 RL: SPN (Synthetic preparation); PREP (Preparation)
 (preparation of)
 RN 122823-57-8 HCPLUS
 CN Benzofuran, 2,3-dihydro-2-[(phenyltelluro)methyl]- (9CI) (CA INDEX NAME)



IT 35684-37-8
 RL: RCT (Reactant); RACT (Reactant or reagent)
 (reaction of, with nitrobenzenesulfonyl peroxide)
 RN 35684-37-8 HCPLUS
 CN Ditelluride, bis(4-methoxyphenyl) (9CI) (CA INDEX NAME)



IT 32294-60-3, Diphenyl ditelluride
 RL: RCT (Reactant); RACT (Reactant or reagent)
 (reaction of, with nitrobenzenesulfonyl peroxide)
 RN 32294-60-3 HCPLUS
 CN Ditelluride, diphenyl (CA INDEX NAME)



CC 27-13 (Heterocyclic Compounds (One Hetero Atom))
 IT 108078-64-4P 108078-67-7P 113345-02-1P 122823-50-1P
 122823-57-8P 137542-98-4P 137542-99-5P 137543-00-1P
 RL: SPN (Synthetic preparation); PREP (Preparation)
 (preparation of)
 IT 35684-37-8
 RL: RCT (Reactant); RACT (Reactant or reagent)
 (reaction of, with nitrobenzenesulfonyl peroxide)
 IT 882-33-7, Diphenyl disulfide 32294-60-3, Diphenyl
 ditelluride
 RL: RCT (Reactant); RACT (Reactant or reagent)
 (reaction of, with nitrobenzenesulfonyl peroxide)

L29 ANSWER 5 OF 10 HCPLUS COPYRIGHT 2007 ACS on STN

ACCESSION NUMBER: 1991:513992 HCPLUS

DOCUMENT NUMBER: 115:113992

TITLE: Synthesis of alkali metal tellurides and
 ditellurides in THF and their relative
 reactivities towards alkyl bromides: a
 convenient synthesis of dialkyl tellurides and
 dialkyl ditellurides

AUTHOR(S): Bhasin, K. K.; Gupta, Vijay; Sharma, R. P.

CORPORATE SOURCE: Dep. Chem., Panjab Univ., Chandigarh, 160 014,

India

SOURCE:

Indian Journal of Chemistry, Section A:
 Inorganic, Bio-inorganic, Physical, Theoretical
 & Analytical Chemistry (1991), 30A(7), 632-4
 CODEN: ICACEC; ISSN: 0376-4710

DOCUMENT TYPE:

Journal

LANGUAGE:

English

OTHER SOURCE(S):

CASREACT 115:113992

AB Lithium, sodium and potassium reduce smoothly elemental tellurium to telluride (Te^{2-}) and ditelluride (Te^{22-}) anions in THF in the presence of catalytic amts. of naphthalene. The relative reactivities of these alkali metal tellurides towards alkyl bromides have been investigated and a number of dialkyl tellurides, e.g., Bu_2Te and dialkyl ditellurides were prepared in good to excellent yields.

IT 20727-11-1P 26105-63-5P 62654-03-9P

77129-69-2P 131443-43-1P 135764-72-6P

RL: SPN (Synthetic preparation); PREP (Preparation)
 (preparation of)

RN 20727-11-1 HCAPLUS

CN Ditelluride, bis(phenylmethyl) (CA INDEX NAME)

 $\text{Ph}-\text{CH}_2-\text{Te}-\text{Te}-\text{CH}_2-\text{Ph}$

RN 26105-63-5 HCAPLUS

CN Ditelluride, diethyl (CA INDEX NAME)

 $\text{Et}-\text{Te}-\text{Te}-\text{Et}$

RN 62654-03-9 HCAPLUS

CN Benzene, 1,1'-(tellurobis(methylene)]bis- (9CI) (CA INDEX NAME)

 $\text{Ph}-\text{CH}_2-\text{Te}-\text{CH}_2-\text{Ph}$

RN 77129-69-2 HCAPLUS

CN Ditelluride, dibutyl (CA INDEX NAME)

 $\text{n-Bu}-\text{Te}-\text{Te}-\text{Bu-n}$

RN 131443-43-1 HCAPLUS

CN Ditelluride, bis(2-methoxyethyl) (9CI) (CA INDEX NAME)

 $\text{MeO}-\text{CH}_2-\text{CH}_2-\text{Te}-\text{Te}-\text{CH}_2-\text{CH}_2-\text{OMe}$

RN 135764-72-6 HCAPLUS

CN Ditelluride, bis(2-ethoxyethyl) (9CI) (CA INDEX NAME)

 $\text{EtO}-\text{CH}_2-\text{CH}_2-\text{Te}-\text{Te}-\text{CH}_2-\text{CH}_2-\text{OEt}$

CC 23-13 (Aliphatic Compounds)
 Section cross-reference(s): 78
 IT 91-20-3, Naphthalene, uses and miscellaneous
 RL: CAT (Catalyst use); USES (Uses)
 (catalysts, for reaction of tellurium with alkali metals)
 IT 627-54-3P 20727-11-1P 26105-63-5P 38788-38-4P
 62654-03-9P 77129-69-2P 131443-42-0P
 131443-43-1P 135764-71-5P 135764-72-6P
 RL: SPN (Synthetic preparation); PREP (Preparation)
 (preparation of)

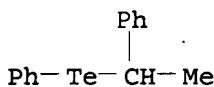
L29 ANSWER 6 OF 10 HCAPLUS COPYRIGHT 2007 ACS on STN
 ACCESSION NUMBER: 1989:423137 HCAPLUS
 DOCUMENT NUMBER: 111:23137
 TITLE: Catalytic oxidation of olefins using diphenyl ditelluride
 AUTHOR(S): Kambe, Nobuaki; Fujioka, Toyozo; Ogawa, Akiya;
 Miyoshi, Noritaka; Sonoda, Noboru
 CORPORATE SOURCE: Fac. Eng., Osaka Univ., Suita, 565, Japan
 SOURCE: Phosphorus and Sulfur and the Related Elements (1988), Volume Date 1987, 38(1-2), 167-75
 CODEN: PREEDF; ISSN: 0308-664X
 DOCUMENT TYPE: Journal
 LANGUAGE: English
 OTHER SOURCE(S): CASREACT 111:23137
 AB Reaction of aliphatic alkenes (e.g., 1-octene) with Me₃COOH and PhTeTePh in MeOH containing H₂SO₄ gave methoxytellurenylation products [e.g., H(CH₂)₆CH(OMe)CH₂TePh] regioselectively. Cyclohexene gave only trans-1-methoxy-2-(phenyltelluro)cyclohexane. Under similar conditions, aromatic alkenes (e.g., p-MeC₆H₄CH:CH₂) gave dimethoxy derivs. [e.g., p-MeC₆H₄CH(OMe)CH₂OMe]. Other oxidants (O₂, H₂O₂, m-ClC₆H₄CO₂OH) were also effective. The mechanism is discussed.
 IT 32294-60-3, Diphenyl ditelluride
 RL: CAT (Catalyst use); USES (Uses)
 (catalyst, for oxidation of alkenes with Bu hydroperoxide-methanol)
 RN 32294-60-3 HCAPLUS
 CN Diphenyl ditelluride (CA INDEX NAME)

Ph—Te—Te—Ph

IT 32344-00-6P 121335-32-8P
 RL: RCT (Reactant); SPN (Synthetic preparation); PREP (Preparation); RACT (Reactant or reagent)
 (preparation and methoxylation of)
 RN 32344-00-6 HCAPLUS
 CN Benzene, [(phenylmethyl)telluro]- (CA INDEX NAME)

Ph—CH₂—Te—Ph

RN 121335-32-8 HCAPLUS
 CN Benzene, [(1-phenylethyl)telluro]- (CA INDEX NAME)



CC 25-9 (Benzene, Its Derivatives, and Condensed Benzenoid Compounds)
 ST alkene aliph methoxytellurenylation regiochem; arom alkene
 methoxylation ditelluride **catalyst**; phenyltelluroalkane
 methoxy; oxidn arylalkene hydroperoxide methanol
 IT Methoxylation **catalysts**
 (di-Ph ditelluride, for aromatic alkenes with Bu
 hydroperoxide-methanol)
 IT 32294-60-3, Diphenyl ditelluride
 RL: CAT (Catalyst use); USES (Uses)
 (catalyst, for oxidation of alkenes with Bu
 hydroperoxide-methanol)
 IT 32344-00-6P 121335-32-8P
 RL: RCT (Reactant); SPN (Synthetic preparation); PREP (Preparation);
 RACT (Reactant or reagent)
 (preparation and methoxylation of)

L29 ANSWER 7 OF 10 HCAPLUS COPYRIGHT 2007 ACS on STN

ACCESSION NUMBER: 1989:406962 HCAPLUS
 DOCUMENT NUMBER: 111:6962

TITLE: A new and efficient reaction for the synthesis
 of the carbon-carbon bond

AUTHOR(S): Barton, Derek H. R.; Ozbalik, Nubar; Ramesh,
 Manian

CORPORATE SOURCE: Dep. Chem., Texas A and M Univ., College
 Station, TX, 77843, USA

SOURCE: Tetrahedron Letters (1988), 29(29), 3533-6
 CODEN: TELEAY; ISSN: 0040-4039

DOCUMENT TYPE: Journal

LANGUAGE: English

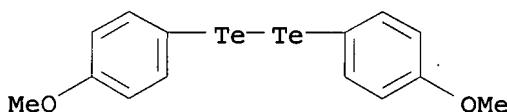
OTHER SOURCE(S): CASREACT 111:6962

AB Sym. and unsym. tellurides R₁TeR₂ (R₁ = anisyl, PhCH₂CH₂; R₂ =
 anisyl, PhCH₂CH₂, PhCH₂, 1-adamantyl, C₁₅H₃₁) were treated with Pd
 in MeCN to give the resp. R₁R₂; cross-coupling was not observed
 Similarly, dianisyl ditelluride was converted to MeOC₆H₄C₆H₄OMe.

IT 35684-37-8 119784-58-6, Benzyl phenethyl telluride
 RL: RCT (Reactant); RACT (Reactant or reagent)
 (demetallation of, **catalysts** for)

RN 35684-37-8 HCAPLUS

CN Ditelluride, bis(4-methoxyphenyl) (9CI) (CA INDEX NAME)



RN 119784-58-6 HCAPLUS

CN Benzene, [[(2-phenylethyl)telluro]methyl]- (9CI) (CA INDEX NAME)

Ph-CH₂-CH₂-Te-CH₂-Ph

CC 25-2 (Benzene, Its Derivatives, and Condensed Benzenoid Compounds)
 Section cross-reference(s): 23, 24, 29
 ST demetalation aryl telluride **catalyst**; biphenyl; alkyl
 telluride demetalation **catalyst**; adamantyl telluride
 demetalation **catalyst**
 IT Tellurides
 RL: RCT (Reactant); RACT (Reactant or reagent)
 (demetalation of, **catalysts** for)
 IT Substitution reaction **catalysts**
 (tellurylation, retro, palladium, for aryl and arylalkyl
 tellurides)
 IT 7440-05-3, Palladium, uses and miscellaneous
 RL: CAT (Catalyst use); USES (Uses)
 (**catalysts**, for demetalation of aryl and arylalkyl
 tellurides)
 IT 4456-34-2 35684-37-8 71766-40-0, Diphenethyl telluride
 95177-44-9 119784-58-6, Benzyl phenethyl telluride
 119784-59-7
 RL: RCT (Reactant); RACT (Reactant or reagent)
 (demetalation of, **catalysts** for)

L29 ANSWER 8 OF 10 HCAPLUS COPYRIGHT 2007 ACS on STN
 ACCESSION NUMBER: 1985:184440 HCAPLUS
 DOCUMENT NUMBER: 102:184440
 TITLE: Organotelluriums. V. Nucleophilic cleavages of
 esters and ethers with
 phenyltellurotrimethylsilane
 AUTHOR(S): Sasaki, Kazuaki; Aso, Yoshio; Otsubo, Tetsuo;
 Ogura, Fumio
 CORPORATE SOURCE: Fac. Eng., Hiroshima Univ., Higashi-Hiroshima,
 724, Japan
 SOURCE: Tetrahedron Letters (1985), 26(4), 453-6
 CODEN: TELEAY; ISSN: 0040-4039
 DOCUMENT TYPE: Journal
 LANGUAGE: English
 OTHER SOURCE(S): CASREACT 102:184440
 AB Treatment of esters and ethers with PhTeSiMe₃ in the presence of
 ZnI₂ **catalyst** under very mild conditions gave
 C-telluration and O-silylation products via nucleophilic cleavages
 of the C-O bonds. Thus, cleavage of butyrolactone gave
 PhTe(CH₂)₃CO₂H and that of methyloxirirane gave PhTeCH₂CHMeOSiMe₃.
 IT 32344-00-6P
 RL: SPN (Synthetic preparation); PREP (Preparation)
 (preparation of)
 RN 32344-00-6 HCAPLUS
 CN Benzene, [(phenylmethyl)telluro]- (CA INDEX NAME)

Ph—CH₂—Te—Ph

IT 32294-60-3
 RL: RCT (Reactant); RACT (Reactant or reagent)
 (reaction of, with sodium and trimethylsilyl chloride)
 RN 32294-60-3 HCAPLUS
 CN Ditelluride, diphenyl (CA INDEX NAME)

Ph—Te—Te—Ph

CC 21-2 (General Organic Chemistry)
 IT 872-89-9P 1529-17-5P 1825-61-2P 6221-88-1P 14642-79-6P
 32343-98-9P 32344-00-6P 91489-38-2P 96185-49-8P
 96185-50-1P 96185-51-2P 96185-52-3P 96185-53-4P 96185-54-5P
 96185-55-6P 96185-56-7P 96185-57-8P 96185-58-9P 96206-05-2P
 RL: SPN (Synthetic preparation); PREP (Preparation)
 (preparation of)
 IT 32294-60-3
 RL: RCT (Reactant); RACT (Reactant or reagent)
 (reaction of, with sodium and trimethylsilyl chloride)

L29 ANSWER 9 OF 10 HCPLUS COPYRIGHT 2007 ACS on STN

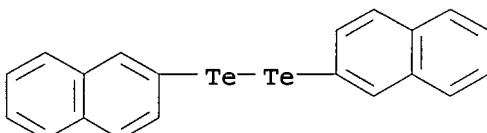
ACCESSION NUMBER: 1985:166398 HCPLUS
 DOCUMENT NUMBER: 102:166398
 TITLE: Alkaline hydrolysis of diaryl ditellurides under
 phase transfer conditions; synthesis of alkyl
 aryl tellurides
 AUTHOR(S): Comasseto, J. V.; Ferreira, J. T. B.; Val, J. A.
 Fontanillas
 CORPORATE SOURCE: Inst. Quim., Univ. Sao Paulo, Sao Paulo, Brazil
 SOURCE: Journal of Organometallic Chemistry (1984),
 277(2), 261-6
 CODEN: JORCAI; ISSN: 0022-328X
 DOCUMENT TYPE: Journal
 LANGUAGE: English
 OTHER SOURCE(S): CASREACT 102:166398

AB The disproportionation reaction of RTeTeR (R = Ph, 4-MeC₆H₄, 4-MeOC₆H₄, 4-EtOC₆H₄, 2-naphthyl) with NaOH under phase transfer conditions at room temperature is carried out with 2HT-75, a mixture of dialkyldimethylammonium chlorides. The intermediates aryl tellurolates react in situ with alkyl halides to give 52-72% alkyl aryl tellurides RTeR₁ (R₁ = Bu, CH₂CH₂CHMe₂, CH₂CHMe₂, CH₂CH₂CHMeBr, decyl, CH₂Ph, CH₂Cl, CH₂CH₂Ph, allyl, CH₂CH:CHPh, CH₂SePh, 2-cyclohexen-1-yl).

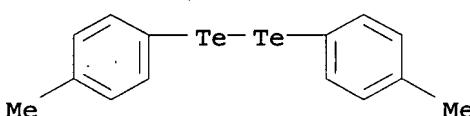
IT 1666-12-2 32294-57-8 32294-60-3
 35684-37-8 35684-38-9
 RL: RCT (Reactant); RACT (Reactant or reagent)
 (disproportionation reactions of, phase transfer catalysis in)

RN 1666-12-2 HCPLUS

CN Ditelluride, di-2-naphthalenyl (CA INDEX NAME)



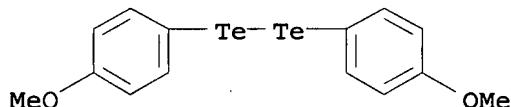
RN 32294-57-8 HCPLUS
 CN Ditelluride, bis(4-methylphenyl) (CA INDEX NAME)



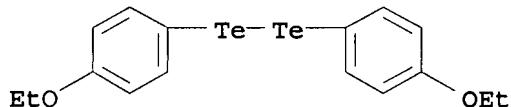
RN 32294-60-3 HCAPLUS
 CN Ditelluride, diphenyl (CA INDEX NAME)

Ph—Te—Te—Ph

RN 35684-37-8 HCAPLUS
 CN Ditelluride, bis(4-methoxyphenyl) (9CI) (CA INDEX NAME)



RN 35684-38-9 HCAPLUS
 CN Ditelluride, bis(4-ethoxyphenyl) (9CI) (CA INDEX NAME)



IT 32344-00-6P
 RL: SPN (Synthetic preparation); PREP (Preparation)
 (preparation of)
 RN 32344-00-6 HCAPLUS
 CN Benzene, [(phenylmethyl)telluro]- (CA INDEX NAME)

Ph—CH₂—Te—Ph

CC 25-14 (Benzene, Its Derivatives, and Condensed Benzenoid Compounds)
 IT Disproportionation catalysts
 (phase-transfer, for diarylditellurides)
 IT 1666-12-2 32294-57-8 32294-60-3
 35684-37-8 35684-38-9
 RL: RCT (Reactant); RACT (Reactant or reagent)
 (disproportionation reactions of, phase transfer catalysis in)
 IT 32343-98-9P 32344-00-6P 55136-86-2P 55136-87-3P
 56950-02-8P 81609-30-5P 83817-36-1P 87550-08-1P 95849-63-1P
 95849-64-2P 95849-65-3P 95849-66-4P 95849-67-5P 95849-68-6P
 95849-69-7P 95849-70-0P
 RL: SPN (Synthetic preparation); PREP (Preparation)
 (preparation of)

L29 ANSWER 10 OF 10 HCAPLUS COPYRIGHT 2007 ACS on STN

ACCESSION NUMBER: 1979:532159 HCAPLUS

DOCUMENT NUMBER: 91:132159

TITLE: Organotellurium (II) and (IV) compounds in
 heat-developable imaging materials and process
 with physically-developable nuclei

INVENTOR(S): Lelemental, Mark; Gysling, Henry J.

PATENT ASSIGNEE(S): Eastman Kodak Co., USA

SOURCE: U.S., 12 pp.

DOCUMENT TYPE: Patent
 LANGUAGE: English
 FAMILY ACC. NUM. COUNT: 3
 PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
US 4152155	A	19790501	US 1977-848063	197711 03
CA 1081949	A1	19800722	CA 1976-259885	197608 26
FR 2357932	A1	19780203	FR 1977-20874	197707 07
FR 2357932	B1	19790427		
JP 53007226	A	19780123	JP 1977-81119	197707 08
GB 1580073	A	19801126	GB 1977-28794	197707 08
US 4144062	A	19790313	US 1977-848062	197711 03
PRIORITY APPLN. INFO.:			US 1976-703477	A2 197607 08

AB An imaging composition containing a Te(II) or Te(IV) compound as an oxidizing agent and a reducing agent is described. The composition, which is especially useful in heat-developable materials containing sources of phys. developable nuclei, provides an improved amplified image by heating the element to moderately elevated temps. Thus, a paper support was coated at 9 mils (wet) with a solution prepared by mixing a 10% solution of 2-hydroxy-5-methyl-3-piperidino-2-cyclopentenone in Me₂CO-PhMe-DMF (45:45:10) 2 mL and a 2% solution of poly(vinyl butyral) 10 mL containing Te[S₂CN(Et₂)₂] 40 mg. The resulting heat-developable material was then laminated in face-to-face contact with a step tablet distribution of Ag nuclei, vapor deposited on a poly(ethylene terephthalate) film support. The resulting so-called sandwich was then passed between heated rollers at 175° to provide heating at this temperature for 15 s. This produced dark Te deposits of neutral (black) tone in the areas in which the Ag nuclei and the layer containing the Te complex were adjacent.

IT 32294-60-3 62654-04-0

RL: USES (Uses)

(photosensitive compns. containing, for heat-developable photoimaging materials for use with phys. developable nuclei)

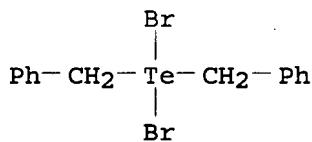
RN 32294-60-3 HCAPLUS

CN Ditelluride, diphenyl (CA INDEX NAME)

Ph—Te—Te—Ph

RN 62654-04-0 HCAPLUS

CN Tellurium, dibromobis(phenylmethyl)-, (T-4)- (9CI) (CA INDEX NAME)



IC G03C005-24; G03C001-76; G03C001-00; G03C001-02

INCL 096048000PD

CC 74-8 (Radiation Chemistry, Photochemistry, and Photographic Processes)

IT 7440-05-3, uses and miscellaneous 7440-22-4, uses and miscellaneous 7440-50-8, uses and miscellaneous 7440-57-5, uses and miscellaneous

RL: CAT (Catalyst use); USES (Uses)
(catalysts, for use with photosensitive photoimaging compns. containing organotellurium compound)

IT 50-81-7, uses and miscellaneous 92-43-3 119-47-1 837-13-8

1838-13-7 1948-33-0 2049-55-0 2654-58-2 5471-90-9

5930-28-9 6112-49-8 13047-13-7 15080-52-1 32294-60-3

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